

L Number	Hits	Search Text	DB	Time stamp
1	1868	bAse and collector And emitter and silicide\$4	USPAT	2003/07/01 12:22
2	210	(bAse and collector And emitter and silicide\$4) and method And Aperture\$2	USPAT	2003/07/01 12:23
3	135	((bAse and collector And emitter and silicide\$4) and method And Aperture\$2) And (metAl\$4 with silicide)	USPAT	2003/07/01 12:23
4	53	((((bAse and collector And emitter and silicide\$4) and method And Aperture\$2) And (metAl\$4 with silicide)) and (wet with etch\$4)	USPAT	2003/07/01 12:24
5	44	(((((bAse and collector And emitter and silicide\$4) and method And Aperture\$2) And (metAl\$4 with silicide)) and (wet with etch\$4)) and (thermAl\$4 with oxide)	USPAT	2003/07/01 12:25
6	38	(((((bAse and collector And emitter and silicide\$4) and method And Aperture\$2) And (metAl\$4 with silicide)) and (wet with etch\$4)) and ((thermAl\$4 with oxide) with side wAlI\$2)	USPAT	2003/07/01 12:26
7	38	(((((bAse and collector And emitter and silicide\$4) and method And Aperture\$2) And (metAl\$4 with silicide)) and (wet with etch\$4)) and ((thermAl\$4 with oxide) with side wAlI\$2)) and trAnsistor\$2	USPAT	2003/07/01 12:26